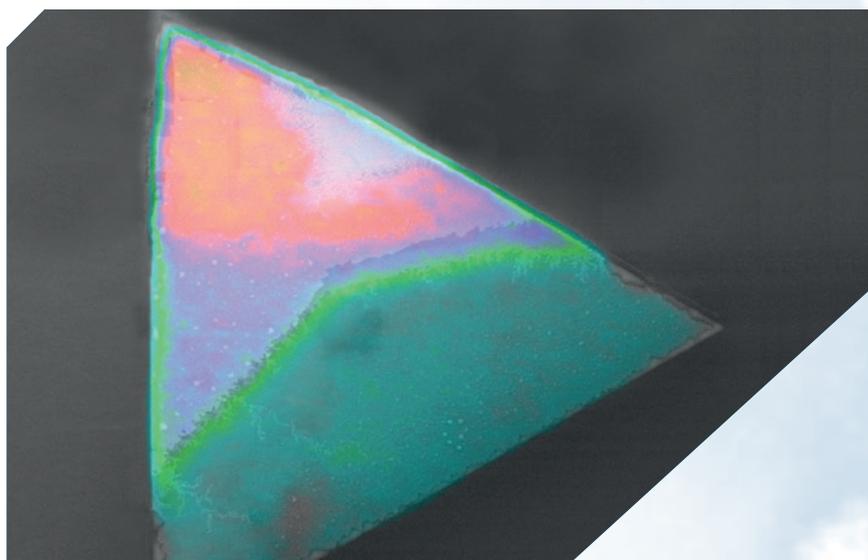
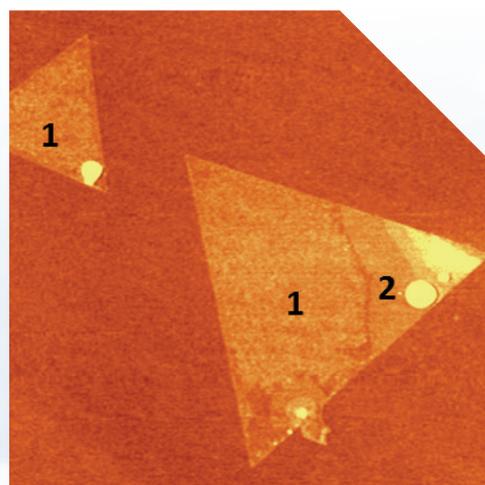
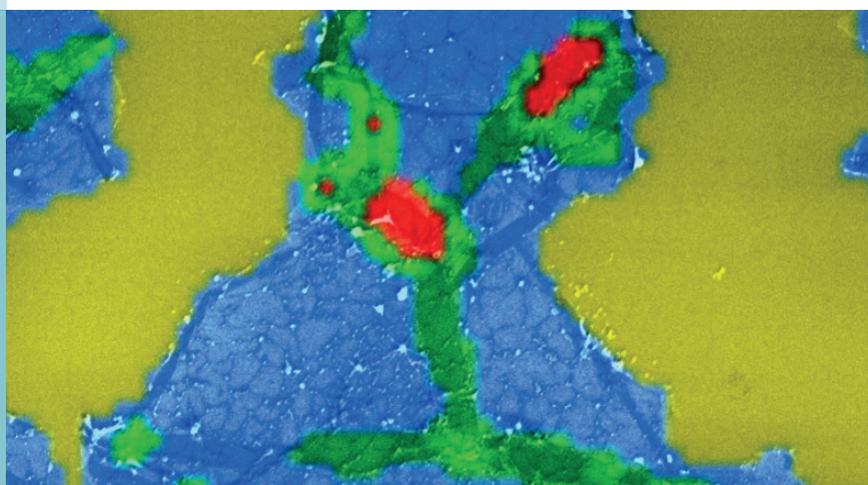
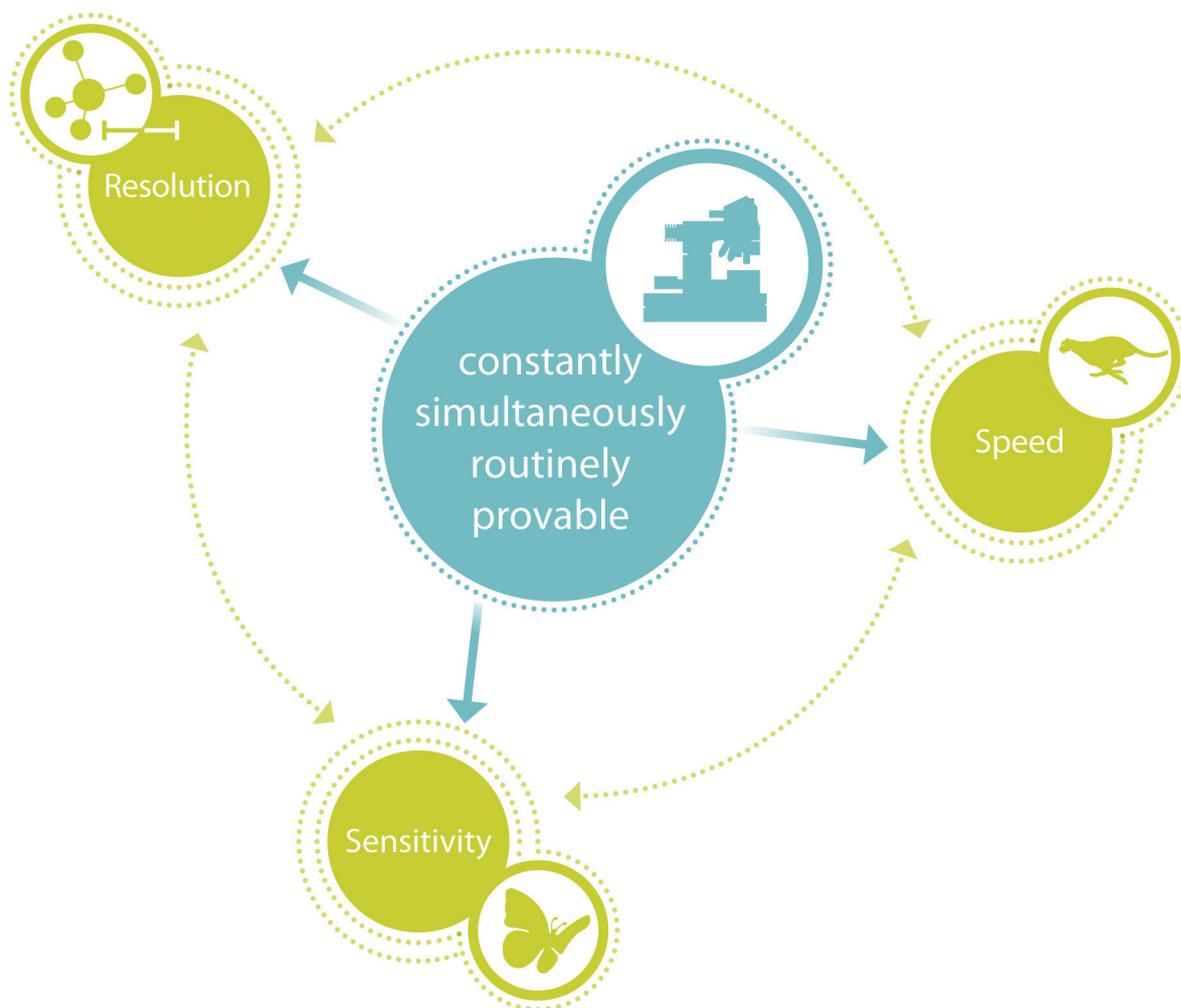


# Correlative Confocal Raman Microscopy for 2D Materials Investigation





## Confocal Raman Microscopy

The outstanding sensitivity of WITec's optical systems reduces acquisition times for single Raman spectra down to well below 1 ms and enables ULTRAFAST RAMAN IMAGING® and time-resolved micro-Raman spectroscopy with unprecedented resolution. Detecting signals from weak Raman scatterers or extremely low material concentrations or volumes with the lowest excitation energy levels is the unrivaled advantage of WITec systems. All Raman spectra are collected and processed by the WITec software suites, which also provide for post-processing and in-depth analysis of spectral data.

## Comprehensive analyses of 2D materials with correlative Raman microscopy

The mechanical isolation of single-layer graphene with the help of adhesive tape in 2004 kicked off the rapid growth in research on materials consisting of only one or a few layers of atoms, defined as 2D materials. Different from bulk matter, they display interesting semiconducting characteristics that inspired an extensive exploration of their structural, electronic and optical properties. While graphene is still the most prominent example of a single-layered semiconducting material, other 2D materials such as transition metal dichalcogenides (TMDCs) and black phosphorus also possess sizeable band-gaps. In this application note we will introduce both confocal Raman microscopy as a stand-alone technique and correlative Raman microscopy for the comprehensive investigation of various 2D materials.

Confocal Raman imaging is an ideal method for studying 2D thin films, revealing their molecular characteristics through a non-destructive and fast procedure. It is used to discern the orientation of their layers and to investigate defects, strain and functionalization, as their Raman properties are determined by molecular bonds, relative orientation and number of layers. Their morphological details can be visualized with other high-resolution microscopy methods such as Scanning Electron Microscopy (SEM). By correlating the information of both approaches, 2D materials can be even more thoroughly analyzed.

WITec has developed microscopes that integrate confocal Raman imaging and optionally Atomic Force Microscopy (AFM), Scanning Near-field Optical Microscopy (SNOM) or SEM into one instrument for highly sensitive and efficient correlative microscopy.

## Raman-SEM (RISE) analysis of graphene

RISE Microscopy is the combination of confocal Raman Imaging and Scanning Electron Microscopy (SEM). It incorporates the sensitivity of the non-destructive, spectroscopic Raman technique along with the high-resolution of electron microscopy.

In Fig. 1 the SEM (a) and RISE (c) images of a CVD-grown graphene sheet deposited on a Si/SiO<sub>2</sub> substrate are presented. Layer numbers were deduced from the Raman spectra (Fig. 1b). The colors used represent a single layer (blue, dark green) with different grade of defects and more than one layer (light green, red). The RISE image highlights the large amount of defects in the blue area, in good agreement with the high-resolution SEM image.

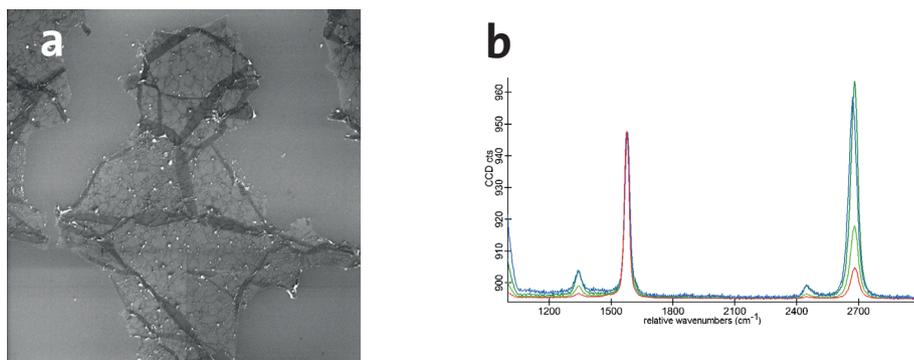
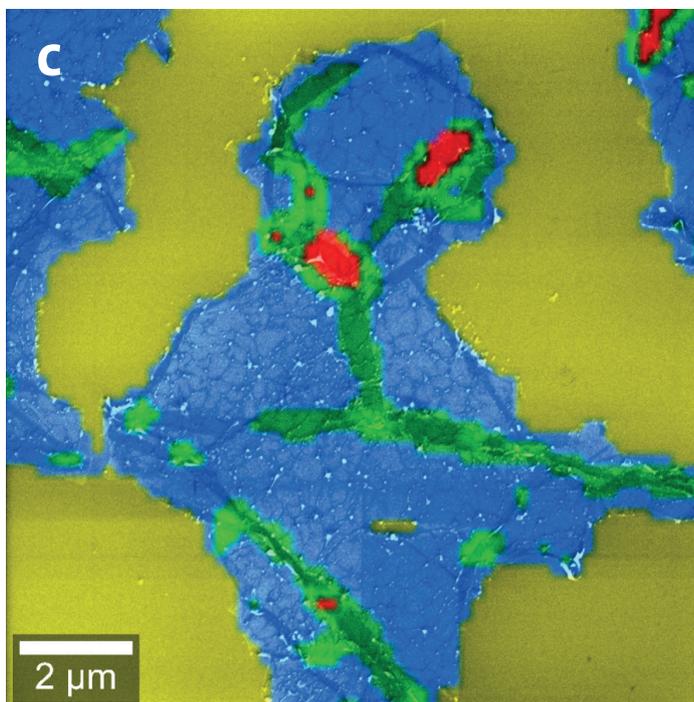


Fig. 1: RISE microscopy of graphene (a) SEM image of a graphene sample. (b) Raman spectra of graphene. (c) SEM image overlaid with the color-coded confocal Raman image. The colors display the graphene layers and wrinkles. Image parameters: 20 x 20 μm<sup>2</sup>, 150 x 150 pixels = 22,500 spectra, integration time: 0.05 s/spectrum, 1 layer (blue, dark green), more than 1 layer (light green, red), Si (yellow).



## RISE microscopy of MoS<sub>2</sub>

RISE microscopy reveals structure as well as crystalline and exciton dynamics of few-layered transition metal dichalcogenides (TMDCs).

CVD-grown monolayers of MoS<sub>2</sub> form triangular two-dimensional crystals. Twin crystals of MoS<sub>2</sub> on SiO<sub>2</sub>/Si appear in the SEM image as star-shaped forms (Fig. 2b). The Raman spectra of MoS<sub>2</sub> monolayers show the characteristic E'<sub>2g</sub> and A'<sub>1g</sub> Raman band modes of MoS<sub>2</sub> at 385 and 403 relative wavenumbers (cm<sup>-1</sup>), respectively (Fig. 2a). With an increasing number of layers the two Raman bands drift apart due to in-plane and out-of-plane (inter-layer) vibrations.

Here the green spectrum indicates monolayer MoS<sub>2</sub>, while the blue and red spectra signify edges and defects, respectively.

The spectral information was used to create a Raman image which was overlaid on the SEM image to result in a RISE image (Fig. 2c). The grain boundaries visible in the SEM image correlate perfectly with the areas where Raman signals indicate crumpled or overlapping edges, highlighting the effectiveness of RISE imaging for characterizing MoS<sub>2</sub> crystals.

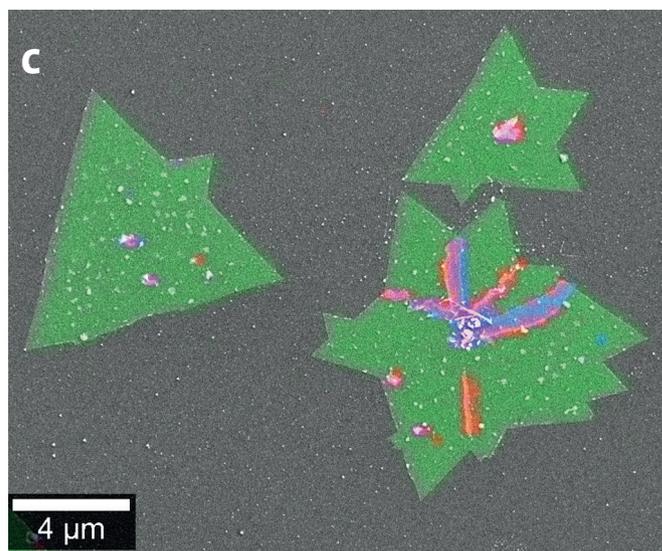
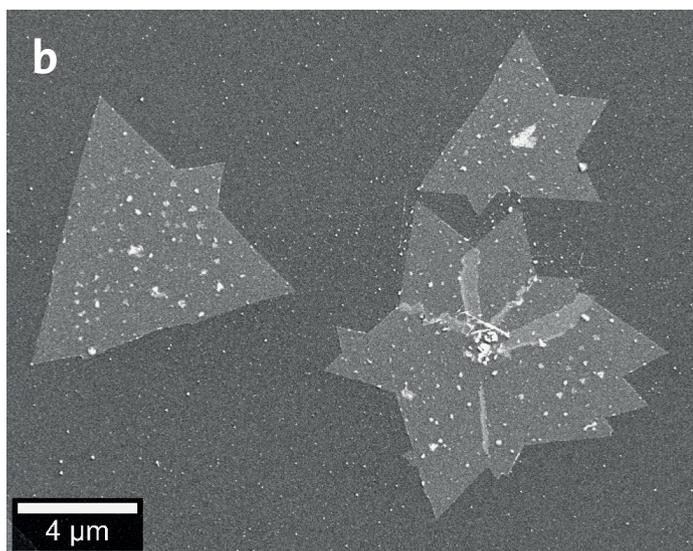
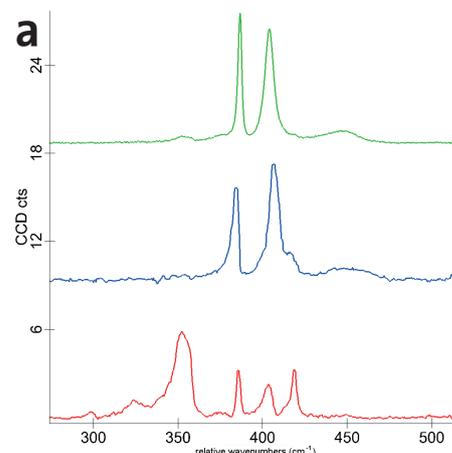


Fig. 2: RISE microscopy of MoS<sub>2</sub> crystals

(a) Raman spectra of MoS<sub>2</sub>: green = 1L MoS<sub>2</sub>, blue and red = edges and defects.

(b) SEM image of MoS<sub>2</sub> crystals.

(c) Color-coded Raman image derived from the spectral information overlaid on the SEM image to produce the RISE image.

Sample courtesy of Ting Yu, Nanyang Technological University, Singapore.

## Correlative Raman - AFM - SNOM - Photoluminescence imaging reveals layers and defects of WS<sub>2</sub> crystals

WS<sub>2</sub> crystals CVD-grown on a Si/SiO<sub>2</sub> substrate form triangular islands. Atomic Force Microscopy (AFM) was used to measure their layer thickness (Fig. 3a). The flakes are comprised of 1, 2 and more layers. The Raman spectrum of WS<sub>2</sub> displays a typical in-plane ( $E'_2/E_g$ ) mode at 352 relative wavenumbers ( $\text{cm}^{-1}$ ) and an out-of-plane ( $A'_1/A_{1g}$ ) mode at 416 relative wavenumbers ( $\text{cm}^{-1}$ ) (Peimyoo et al. 2014). The Raman image of the intensity at 416 relative wavenumbers ( $\text{cm}^{-1}$ ) shows that this signal is strongest in those parts of the crystals that consist of two or more layers and defects, respectively (Fig. 3b).

The number of layers and the type of layer stacking influences not only Raman peaks' intensities and positions but also the intensity of photoluminescence peaks and their positions. Due to its direct band-gap, monolayer WS<sub>2</sub> shows a strong PL around 635 nm when excited with a 532 nm laser (Fig. 3c). This PL decreases significantly with increasing layer numbers because the direct bandgap that is present solely in single-layered TMDCs allows for direct recombination of electrons and holes (Fig. 3d). Also the PL peak position varies and PL lifetime changes with thickness: the more layers the more PL shifts to the red (Fig. 3e) and PL lifetime grows shorter (Fig. 3f).

Scanning Near-field Optical Microscopy (SNOM) with up to 60 nm spatial resolution was also used for TMDC characterization (Lee et al. 2015, 2017). Here, strong PL indicates edge defects in the material, as shown in a high-resolution SNOM image of another WS<sub>2</sub> crystal (Fig. 3g). These can also be deduced from PL peak position changes (Fig. 3h).

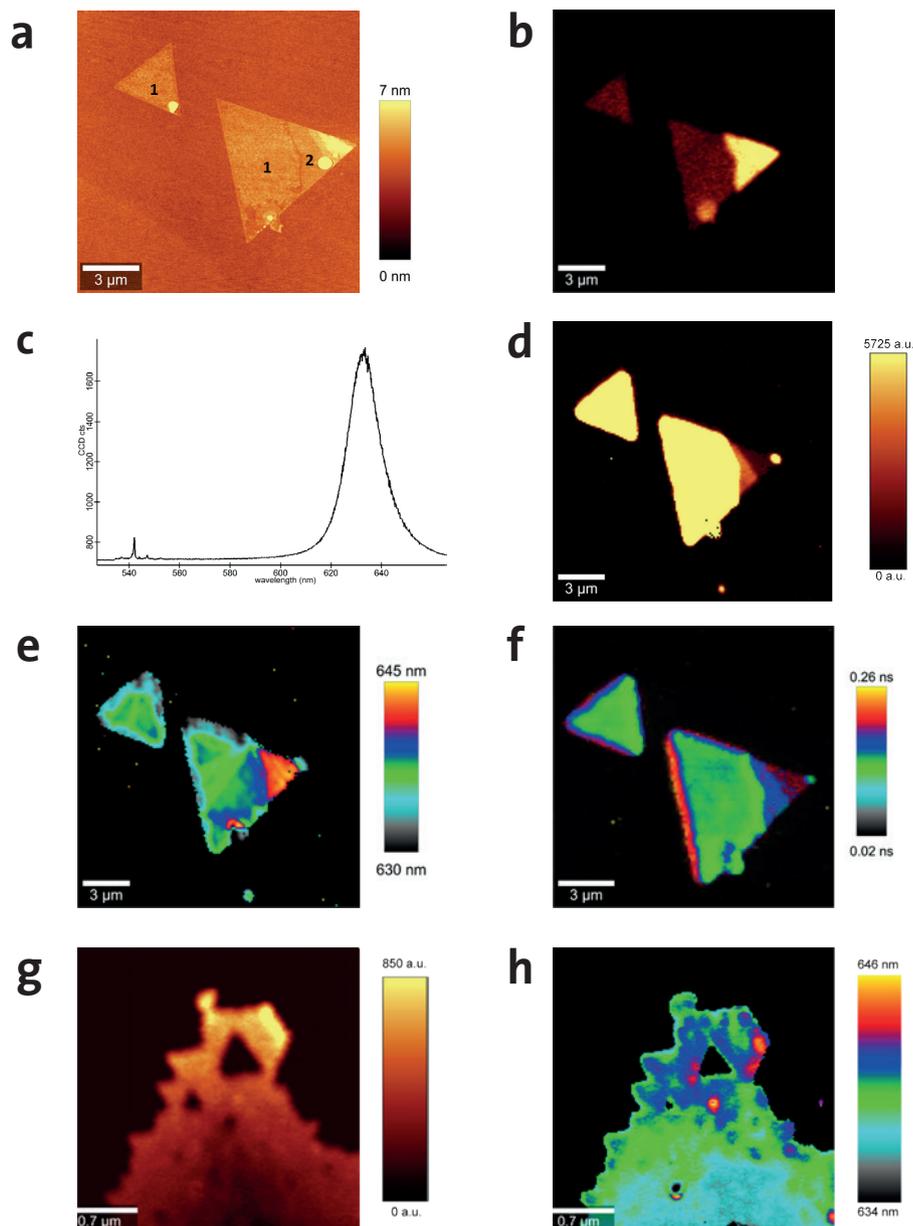


Fig. 3: Correlative AFM-SNOM-PL imaging of WS<sub>2</sub>  
 (a) AFM image of CVD-grown WS<sub>2</sub> flakes on a Si/SiO<sub>2</sub> substrate with varying numbers of layers (1, 2, >2).  
 (b) A peak intensity map of the 416 relative wavenumbers ( $\text{cm}^{-1}$ ) Raman mode.  
 (c) Upon excitation with wavelength of 532 nm, WS<sub>2</sub> shows a very strong PL around 635 nm.  
 (d) PL intensity map of the WS<sub>2</sub> flakes at 635 nm corresponds exactly to the thickness of the material.  
 (e) Position map of PL maxima.  
 (f) PL lifetime map.  
 (g) A high-resolution SNOM-PL image of a WS<sub>2</sub> flake reveals edge defects that correlate with strong PL.  
 (h) The edge defects are also visible in the high-resolution SNOM-PL peak position image.

## RISE imaging and in situ modification of WS<sub>2</sub>

Here we show the analysis and RISE imaging of a multi-layered WS<sub>2</sub> crystal. The high-resolution SEM image (Fig. 4a) shows the typical triangular shape of the material, as well as the heterogeneity of the surface.

A strong WS<sub>2</sub> Raman signal was reported at about 350 relative wavenumbers (cm<sup>-1</sup>) (Wang et al. 2015). Researchers were able to divide this peak into three sub-peaks (Peimyoo et al. 2013). They associated a signal at 344 relative wavenumbers (cm<sup>-1</sup>) with the in-plane E' Raman mode. Using this spectral band we generated a Raman intensity map. Overlaying it with the SEM data produced a RISE image (Fig. 4b).

The Raman signals show that this flake is not homogeneously layered. It contains 1L layers and areas with more layers and also defects. The Raman image corresponds very well to the structures revealed by SEM.

Fig. 4c shows the overlay of the SEM image and an intensity peak map of PL. The WS<sub>2</sub> crystal displays strong and homogenous PL at about 640 nm only in the 1L areas due to the direct bandgap in monolayer WS<sub>2</sub>. Defects seen in the SEM image exhibit PL intensity variations rich in detail. PL intensity perfectly corresponds to the intensity of the Raman signal.

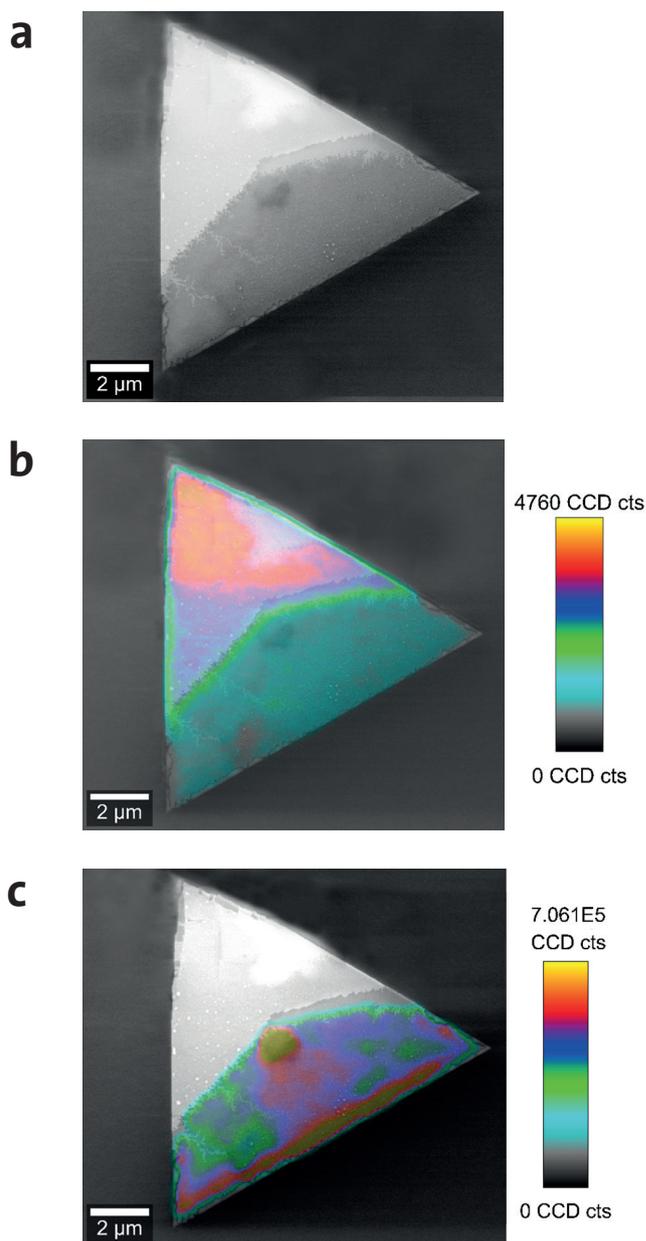


Fig. 4: Correlative RISE and SEM-PL microscopy of WS<sub>2</sub> crystals.

(a) The SEM image of a WS<sub>2</sub> flake reveals defects on the surface and probably adsorbed molecules.  
(b) The correlative RISE image is composed of the SEM image and the corresponding Raman intensity map over the 344 cm<sup>-1</sup> Raman band. The Raman image identifies 1L (cyan), 2L (blue) and 3L (red) areas.  
(c) Overlay of the SEM and PL intensity images shows that the 3L area lacks PL (upper part of the triangle).

Excitation wavelength for Raman and PL imaging = 532 nm.

## Low-frequency Raman modes and imaging of MoSe<sub>2</sub>

Not every transition metal dichalcogenide (TMDC) can be adequately characterized by its vibrational modes between 200 and 500 relative wavenumbers. In some materials typical in-plane ( $E'/E_{2g}$ ) and out-of-plane ( $A'/A'_{1g}$ ) modes, though changing in intensity with increasing thickness of the material, do not show peak shifts. Also, these primary Raman peaks are highly sensitive to strain and folding (Zhang et al. 2013) and therefore cannot be used to unambiguously determine the number of layers.

However, low-frequency in-plane shear modes (SM) and out-of-plane layer-breathing modes (LBM) modes are much more revealing (O'Brien et al. 2016). To measure Raman spectra close to the laser's excitation wavelength at low wavenumbers between 10 and 50  $\text{cm}^{-1}$ , efficient blocking of the Rayleigh line while still transmitting adjacent light is necessary. WITec has developed the RayShield coupler with exactly these features that can be combined with every WITec Raman microscope and is available for 488, 532, 633 and 785 nm lasers.

All measurements of Fig. 5 were carried out by Maria O'Brien, Nigel McEvoy and colleagues (Trinity College, Dublin). The low-frequency spectrum shows that 1L MoSe<sub>2</sub> has no Raman peak in this range (Fig. 5a). With increasing layer numbers SM and LBM peaks occur, shifting in positions and intensities. Accordingly, the flakes that appear to be the thinnest in the optical image (Fig. 5b) are almost invisible in the Raman image, whereas thicker material can be detected by their Raman modes (Fig. 5c). The type of layer stacking also influences the Raman peaks'

intensities and positions. In stable, semi-conducting MoSe<sub>2</sub> with trigonal prismatic coordination the individual layers can combine in two arrangements, called H and R stacking. These so-called polytypes cannot be distinguished from each other in optical images but can be by their distinctive Raman peaks. Intensity changes in Raman modes at 19 and 24 relative wavenumbers ( $\text{cm}^{-1}$ ) reflect differences in the layer stacking. 2L MoSe<sub>2</sub> displays a typical Raman signal at 19 relative wavenumbers ( $\text{cm}^{-1}$ ) that is more intense in the 2H than in the 3R stacking configuration (Fig. 5d). From the peak maximum map at 24 relative wavenumbers ( $\text{cm}^{-1}$ ) it is clear that 3L MoSe<sub>2</sub> shows the highest intensity in the 3R3R configuration followed by 2H3R and

inverted 3R3R stacking (Fig. 5e). O'Brien and colleagues concluded that "... low-frequency Raman mapping can distinguish between different stacking configurations rapidly and non-destructively, allowing TMDCs in different stacking configurations to be identified and studied without the need for high-resolution imaging."

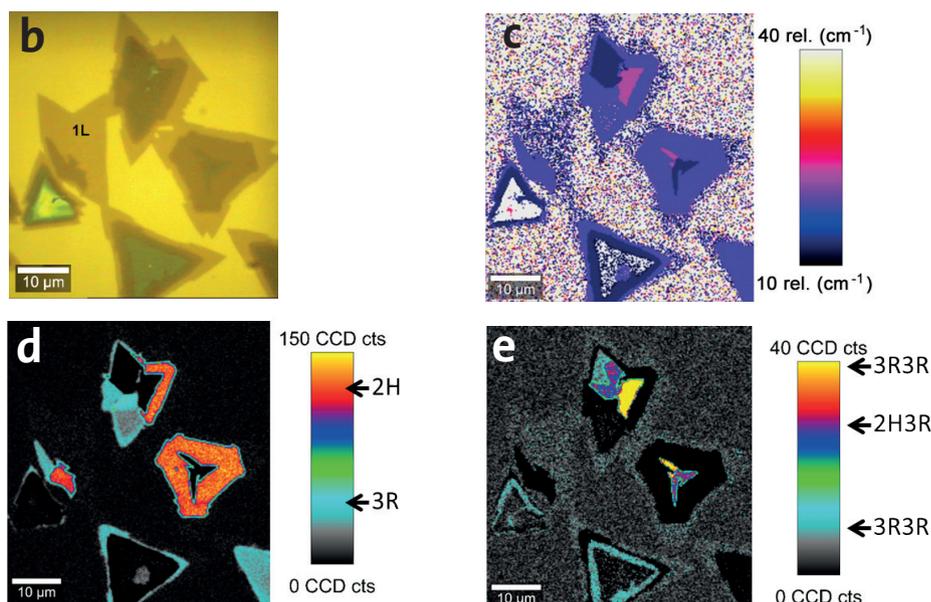


Fig. 5: Low-frequency Raman modes of MoSe<sub>2</sub>

- (a) Low-frequency Raman spectra of 1L, 2L and 3L MoSe<sub>2</sub> with various layer configurations (H and R).
- (b) Optical image of CVD-grown MoSe<sub>2</sub> reveals differences in thickness and structure of the crystals.
- (c) Map of position of maximum peak intensity over the range of 10 to 40 relative wavenumbers ( $\text{cm}^{-1}$ ).
- (d) Peak intensity map of 2L MoSe<sub>2</sub> at 19 relative wavenumbers ( $\text{cm}^{-1}$ )
- (e) Peak intensity map of 3L MoSe<sub>2</sub> at 24 relative wavenumbers ( $\text{cm}^{-1}$ )

RISE  
Raman

alpha300 R



alpha300 RA

alpha300 RS

alpha300 A

alpha300 S



AFM

SNOM

## WITec alpha300 Confocal Raman Microscope Series

alpha300 series: modular and flexible design guarantees advanced confocal Raman imaging with multiple correlative microscopy technique options, such as AFM, SNOM, SEM (RISE), fluorescence, photoluminescence and topographic Raman imaging (TrueSurface).